

**AMENDMENTS TO THE CLAIMS**

**This listing of claims will replace all prior versions and listings of claims in the application:**

**LISTING OF CLAIMS:**

1. (currently amended): An anisotropic material comprising an alternating-line pattern and a layer of at least one functional compound selected from the group consisting of a semiconductor compound, an electrically conductive compound, a photochromic compound and a thermochromic compound, formed on a surface of the alternating-line pattern, wherein one type of lines in the alternating-line pattern surface comprises a fluorine-containing compound, the fluorine-containing compound is at least one fluorine-containing organic silane compound, fluorine-containing organic thiol compound, fluorine-containing organic disulfide compound, or fluorine-containing organic phosphate ester compound, selected from the group consisting of:
  - (a) a fluorine compound which has a branched perfluoroalkyl group having 5 or less carbon atoms,
  - (b) a fluorine compound having a perfluoropolyether group,
  - (c) a fluorine compound having a polymer structure obtained by polymerizing a monomer which has a perfluoroalkyl group having 5 or less carbon atoms, and
  - (d) a fluorine compound having a linking group which is any one of an urethane group, an ester group, an ether group and an amide group, existing between a perfluoroalkyl group having 5 or less carbon atoms and a functional group which is a silane group, a thiol group, a disulfide group or a phosphoric acid group; orthe fluorine-containing compound is at least one selected from the group consisting of:

(e) an incompletely-condensed silsesquioxane which has a perfluoroalkyl group having 5 or less carbon atoms, represented by the general formula:



wherein R and R' represent Rf, Rf-A, an alkyl group ~~(having having~~ 1 to 22 carbon ~~atoms)~~ atoms, or a derivative of an alkyl group having 1 to 22 carbon atoms provided that at least one of R and R' is Rf or Rf-A wherein Rf represents a perfluoroalkyl group having 5 or less carbon atoms, and A represents an alkylene group having 1 to 4 carbon atoms, a  $-\text{SO}_2\text{N}(\text{R}^{21})\text{R}^{22}$ - group provided that  $\text{R}^{21}$  is an alkyl group having 1 to 4 carbon atoms, and  $\text{R}^{22}$  is an alkylene group having 1 to 4 carbon atoms or a  $-\text{CH}_2\text{CH}(\text{OH})\text{CH}_2-$  group, and l and m represent such a number that a molecular weight of the incompletely-condensed silsesquioxane is within a range from 500 to 100000, and

(f) a completely-condensed silsesquioxane which has a silane group and a perfluoroalkyl group having 5 or less carbon atoms, represented by the formula:



wherein R represents Rf, Rf-A, an alkyl group ~~(having having~~ 1 to 22 carbon ~~atoms)~~ atoms, or a derivative of an alkyl group having 1 to 22 carbon atoms provided that at least one of R is Rf or Rf-A wherein Rf represents a perfluoroalkyl group having 5 or less carbon atoms, A represents an alkylene group having 1 to 4 carbon atoms, a  $-\text{SO}_2\text{N}(\text{R}^{21})\text{R}^{22}$ - group provided that  $\text{R}^{21}$  is an alkyl group having 1 to 4 carbon atoms, and  $\text{R}^{22}$  is an alkylene group having 1 to 4 carbon atoms or a  $-\text{CH}_2\text{CH}(\text{OH})\text{CH}_2-$  group, R' represents an organic group containing  $\text{SiX}_3$ , wherein X is a halogen atom or  $\text{OC}_n\text{H}_{2n+1}$  where  $n=1$  to 4 and l and m represent such a number that a molecular weight of the completely-condensed silsesquioxane is within a range from 500 to 100000.

2. (previously presented): The anisotropic material according to claim 1, wherein a difference between surface free energy of the type of lines comprising the fluorine compound and surface free energy of the other type of lines is at least  $5 \text{ mJ/m}^2$ .
3. (original): The anisotropic material according to claim 1, wherein the alternating-line pattern has a line width of 0.5 to 100  $\mu\text{m}$ .
4. (original): The anisotropic material according to claim 1, wherein the alternating-line pattern has unevenness of not more than 10 nm.
5. (original): The anisotropic material according to claim 1, wherein the shape of droplets is distorted when 2  $\mu\text{L}$  of ethanol is gently dropped from above the alternating-line pattern, and the degree of distortion is at least 1.1 in terms of a ratio  $L/W$  of the length in a major axis ( $L$ ) to the length in a minor axis ( $W$ ) of droplets.
6. (original): The anisotropic material according to claim 1, wherein the alternating-line pattern comprises an organic silane compound, an organic thiol compound, an organic disulfide compound and/or an organic phosphoric acid ester.
7. (withdrawn-currently amended): A method for producing an anisotropic material comprising an alternating-line pattern and a layer of at least one functional compound selected from the group consisting of a semiconductor compound, an electrically conductive compound, a photochromic compound and a thermochromic compound, formed on a surface of the alternating-line pattern, wherein one type of lines in the alternating-line pattern surface comprises a fluorine-containing compound, the fluorine-containing compound is at least one fluorine-containing organic silane compound, fluorine-containing organic thiol compound, fluorine-containing organic disulfide compound, or fluorine-containing organic phosphate ester compound, selected from the group consisting of:

(a) a fluorine compound which has a branched perfluoroalkyl group having 5 or less carbon atoms,

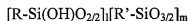
(b) a fluorine compound having a perfluoropolyether group,

(c) a fluorine compound having a polymer structure obtained by polymerizing a monomer which has a perfluoroalkyl group having 5 or less carbon atoms, and

(d) a fluorine compound having a linking group which is any one of an urethane group, an ester group, an ether group and an amide group, existing between a perfluoroalkyl group having 5 or less carbon atoms and a functional group which is a silane group, a thiol group, a disulfide group or a phosphoric acid group; or

the fluorine-containing compound is at least one selected from the group consisting of:

(e) an incompletely-condensed silsesquioxane which has a perfluoroalkyl group having 5 or less carbon atoms, represented by the general formula:



wherein R and R' represent R<sub>f</sub>, R<sub>f</sub>-A, an alkyl group ~~(having having~~ 1 to 22 carbon atoms) atoms, or a derivative of an alkyl group having 1 to 22 carbon atoms provided that at least one of R and R' is R<sub>f</sub> or R<sub>f</sub>-A wherein R<sub>f</sub> represents a perfluoroalkyl group having 5 or less carbon atoms, and A represents an alkylene group having 1 to 4 carbon atoms, a -SO<sub>2</sub>N(R<sup>21</sup>)R<sup>22</sup>- group provided that R<sup>21</sup> is an alkyl group having 1 to 4 carbon atoms, and R<sup>22</sup> is an alkylene group having 1 to 4 carbon atoms or a -CH<sub>2</sub>CH(OH)CH<sub>2</sub>- group, and l and m represent such a number that a molecular weight of the incompletely-condensed silsesquioxane is within a range from 500 to 100000, and

(f) a completely-condensed silsesquioxane which has a silane group and a perfluoroalkyl group having 5 or less carbon atoms, represented by the formula:



wherein R represents Rf, Rf-A, an alkyl group ~~(having having~~ 1 to 22 carbon atoms) atoms, or a derivative of an alkyl group having 1 to 22 carbon atoms provided that at least one of R is Rf or Rf-A wherein Rf represents a perfluoroalkyl group having 5 or less carbon atoms, A represents an alkylene group having 1 to 4 carbon atoms, a  $-\text{SO}_2\text{N}(\text{R}^{21})\text{R}^{22}-$  group provided that  $\text{R}^{21}$  is an alkyl group having 1 to 4 carbon atoms, and  $\text{R}^{22}$  is an alkylene group having 1 to 4 carbon atoms or a  $-\text{CH}_2\text{CH}(\text{OH})\text{CH}_2-$  group,  $\text{R}'$  represents an organic group containing  $\text{SiX}_3$ , wherein X is a halogen atom or  $\text{OC}_n\text{H}_{2n+1}$  where  $n=1$  to 4 and l and m represent such a number that a molecular weight of the completely-condensed silsesquioxane is within a range from 500 to 100000,

which method comprises applying a solution of at least one functional compound selected from the group consisting of a semiconductor compound, an electrically conductive compound, a photochromic compound and a thermochromic compound on the surface of an alternating-line pattern, one type of lines of which comprises a fluorine-containing compound.

8. (withdrawn): The method according to claim 7, wherein a liquid which dissolves the functional compound is a solvent having a surface tension of not more than 30 mN/m.

9. (withdrawn): A method for producing a functional material, comprising using, as a template, a pattern surface composed of plural regions each having different surface free energy, characterized in that:

(1) at least one region of the pattern surface is treated with a fluorine compound, and

(2) the method comprises applying a functional compound solution on the pattern surface and removing a solvent.

10. (canceled).

11. (withdrawn): A functional material produced by the method according to claim 9.
12. (withdrawn): A method for producing a functional material, which comprises applying a functional compound to a pattern surface having at least one region surface-treated with a fluorine compound.
13. (withdrawn): The method according to claim 12, wherein the fluorine compound comprises a fluorine compound having the following structure:
  - (a) a fluorine compound which has a branched fluoroalkyl group having 5 or less carbon atoms,
  - (b) a fluorine compound having a perfluoropolyether group,
  - (c) a fluorine compound having a polymer structure obtained by polymerizing a monomer which has a fluoroalkyl group having 5 or less carbon atoms,
  - (d) a fluorine compound having a linking group which is any one of an urethane group, an ester group, an ether group and an amide group, existing between a fluoroalkyl group having 5 or less carbon atoms and a functional group,
  - (e) an incompletely-condensed silsesquioxane which has a fluoroalkyl group having 5 or less carbon atoms, and
  - (f) a completely-condensed silsesquioxane which has a silane group and a fluoroalkyl group having 5 or less carbon atoms.
14. (withdrawn): A functional material produced by the method according to claim 12.
15. (new): An anisotropic material according to claim 1, wherein both lines of the alternating-line pattern are made of a monomolecular film.

16. (new): The anisotropic material according to claim 1, wherein the layer of the at least one functional compound has a thickness of from 0.1 nm to 100  $\mu\text{m}$ .

17. (new): The anisotropic material according to claim 1, wherein the one type of lines in the alternating-line pattern surface comprises a fluorine-containing organic silane compound having a branched perfluoroalkyl group having 5 or less carbon atoms.

18. (new): The anisotropic material according to claim 1, wherein the one type of lines in the alternating-line pattern surface comprises a fluorine-containing organic silane compound having a branched perfluoroalkyl group having 2 or 3 carbon atoms.